



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

August 4, 2026

IGI Report Number

LG818672557

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

EMERALD CUT

Measurements

8.55 X 5.99 X 3.96 MM

GRADING RESULTS

Carat Weight

2.01 CARATS

Color Grade

E

Clarity Grade

VVS 1

ADDITIONAL GRADING INFORMATION

Polish

EXCELLENT

Symmetry

EXCELLENT

Fluorescence

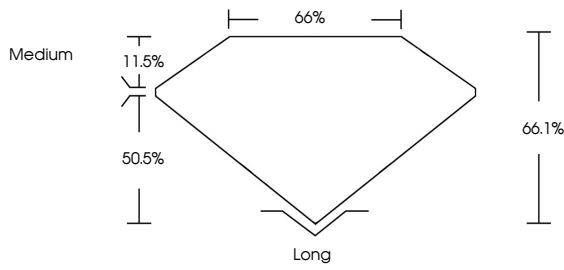
NONE

Inscription(s)

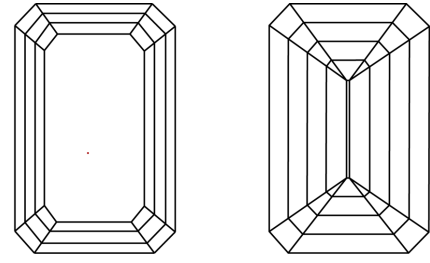
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Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Type IIa

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

COLOR

D

E

F

G

H

I

J

Faint

Very Light

Light

CLARITY

FL

IF

VVS¹⁻²

VS¹⁻²

SI¹⁻²

I¹⁻³

Flawless

Internally Flawless

Very Very Slightly Included

Very Slightly Included

Slightly Included

Included

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EMERALD CUT

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2.01 CARATS

E

VVS 1

66.1%

66%

Medium

Long

EXCELLENT

EXCELLENT

NONE

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Type IIa

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